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(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Ritzdorf et al.

Application No.: 09/885,451

Confirmation No.: 3390

Filed: June 20, 2001

Art Unit: 1742

For: METHOD AND APPARATUS FOR LOW
TEMPERATURE ANNEALING OF
METALLIZATION MICRO-STRUCTURES
IN THE PRODUCTION OF A
MICROELECTRONIC DEVICE

Examiner: W. T. Leader

AMENDMENT UNDER 37 C.F.R. 1.114

MS RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated 12 January 2006, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.